



09-13-04

Express Mail No. EV 463 356 315 US

AR  
IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Gonsalves, Kenneth E.  
Serial No. : 09/992,560  
Filed : November 5, 2001  
For : **High Resolution Resists for Next  
Generation Lithographies**  
Examiner : Lee, Sin J.  
Art Unit : 1752

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT PURSUANT TO 37 C.F.R. § 1.116**

The following Amendment and Remarks are submitted in response to the Final Office Action mailed June 25, 2004. Please amend the above-identified application as set forth below in order to place the application in condition for allowance.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 13 of this paper.

Please  
Do  
Not  
Enter  
S.J.L.  
10-1-2004